L Number	Hits	Search Text	DB	Time stamp
19	0	2-mercaptothiazole and sovlent and resin and	USPAT;	2003/09/05 16:08
		((photoacid acid) near generator) and (basic	US-PGPUB;	,,
		adj compound)	EPO; JPO;	
			DERWENT	
20	299	2-mercaptothiazole	USPAT;	2003/09/05 16:03
			US-PGPUB;	
			EPO; JPO;	
_ ,	-	0	DERWENT	2002/02/05 55 55
21	0	2-mercaptothiazole and solvent and resin and	USPAT;	2003/09/05 16:09
		((photoacid acid) near generator) and (basic adj compound)	US-PGPUB; EPO; JPO;	
			DERWENT	
22	11	2-mercaptothiazole and (resist photoresist)	USPAT:	2003/09/05 16:09
		, and a second s	US-PGPUB;	111, 32, 33
			EPO; JPO;	
		· ·	DERWENT	
23	0	(2-mercaptothiazole and (resist	USPAT;	2003/09/05 16:11
		photoresist)) and (\$5acid near generat\$3)	US-PGPUB;	
		:	EPO; JPO;	
24	2	("6406920"\ DN	DERWENT	2002/00/05 15 15
4	2	("6406830").PN.	USPAT; US-PGPUB;	2003/09/05 16:40
			EPO; JPO;	
		·	DERWENT	·
-	182614	thiol disulfide thiolsulfonate mercapto\$	USPAT;	2003/09/05 16:02
			US-PGPUB;	
			EPO; JPO;	
		21.2.2.2.2.2.2.2.2.2.2.2.2.2.2.2.2.2.2.	DERWENT	0000 (00 (00 00 00 00 00 00 00 00 00 00
-	2424	ped (post-exposure adj delay) (post adj	USPAT;	2003/09/03 11:18
٠.		exposure adj delay)	US-PGPUB;	
		· ·	EPO; JPO; DERWENT	
_	409168	resist photoresist	USPAT;	2003/08/28 17:00
	•	£	US-PGPUB;	
			EPO; JPO;	
			DERWENT	
-	17620	((acid photoacid) near generat\$4)	USPAT;	2003/09/03 16:59
		(photoactive near compound)	US-PGPUB;	
			EPO; JPO;	
_	22477	(basic adj compound) (nitrogen-containing	DERWENT USPAT;	2003/09/03 16:59
	22411	adj compound)	US-PGPUB;	2003/03/03 10:39
		1) - 11.1	EPO; JPO;	
. ]		$(\mathcal{L}, \mathcal{L}) \mathcal{L} \mathcal{L} \mathcal{L}$	DERWENT	
	266188	surfactant	USPAT;	2003/09/03 16:59
		DAALIA	US-PGPUB;	
		Kemove	EPO; JPO;	.
	1005		DERWENT	2002/00/02 17 55
-	1095	dissolution adj inhibitor	USPAT; US-PGPUB;	2003/09/03 17:00
			EPO; JPO;	
			DERWENT	
-	98	(thiol disulfide thiolsulfonate mercapto\$)	USPAT;	2003/08/28 17:01
		and (ped (post-exposure adj delay) (post adj	US-PGPUB;	
		exposure adj delay) ) and (resist	EPO; JPO;	
		photoresist ) and (((acid photoacid) near	DERWENT	
		generat\$4) (photoactive near compound))		0000/00/55
	98	((thiol disulfide thiolsulfonate mercapto\$)	USPAT;	2003/08/28 17:01
1		<pre>and (ped (post-exposure adj delay) (post adj exposure adj delay) ) and (resist</pre>	US-PGPUB;	
i		photoresist ) and ((acid photoacid) near	EPO; JPO; DERWENT	
		generat\$4) (photoactive near compound))) and	JUNITERY I	
		"11"		
-	92	((thiol disulfide thiolsulfonate mercapto\$)	USPAT;	2003/08/28 17:01
		and (ped (post-exposure adj delay) (post adj	US-PGPUB;	
1		exposure adj delay) ) and (resist	EPO; JPO;	
1	Ï	photoresist ) and (((acid photoacid) near	DERWENT	
		<pre>generat\$4) (photoactive near compound))) and surfactant</pre>		+
		SULLACEARE		

	9.8	((thiol disulfide thiolsulfonate mercapto\$) and (ped (post-exposure adj delay) (post adj exposure adj delay) ) and (resist photoresist ) and ((acid photoacid) near generat\$4) (photoactive near compound))) and (surfactant (dissolution adj inhibitor ) ((basic adj compound) (nitrogen-containing adj compound) ))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/08/28 17:02
		<pre>(((thiol disulfide thiolsulfonate mercapto\$) and (ped (post-exposure adj delay) (post adj exposure adj delay) ) and (resist photoresist ) and (((acid photoacid) near generat\$4) (photoactive near compound))) and (surfactant (dissolution adj inhibitor ) ((basic adj compound) (nitrogen-containing adj compound) ))) and ((thiol disulfide thiolsulfonate mercapto\$) same (ped (post-exposure adj delay) (post adj exposure adj delay) ))</pre>	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/08/28 17:02
_	4	(thiol disulfide thiolsulfonate mercaptos) same (ped (post-exposure adj delay) (post adj exposure adj delay) )	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/08/28 17:06
	97	<pre>(((thiol disulfide thiolsulfonate mercapto\$) and (ped (post-exposure adj delay) (post adj exposure adj delay) ) and (resist photoresist ) and (((acid photoacid) near generat\$4) (photoactive near compound))) and (surfactant (dissolution adj inhibitor ) ((basic adj compound) (nitrogen-containing adj compound) ))) not ((thiol disulfide thiolsulfonate mercapto\$) same (ped (post-exposure adj delay) (post adj exposure</pre>	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/08/28 17:06
-	126812	adj delay) )) \$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 18:44
	3	(\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10 ) same (ped (post-exposure adj delay) (post adj exposure adj delay) )	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/08/28 18:38
-	6888	\$10thiolsulfonate\$10 ) and (resist photoresist )	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/08/28 18:40
-	71	((\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10 ) and (resist photoresist )) and (((acid photoacid) near generat\$4) (photoactive near compound)) and ((basic adj compound) (nitrogen-containing adj compound) ) and surfactant	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/09/03 11:30
-	30	(((\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10 ) and (resist photoresist )) and (((acid photoacid) near generat\$4) (photoactive near compound)) and ((basic adj compound) (nitrogen-containing adj compound) ) and surfactant ) and (dissolution adj inhibitor )	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/08/28 18:41

	_			
-	25	1	USPAT;	2003/09/03 11:15
		\$10thiolsulfonate\$10 ) and (resist	US-PGPUB;	
		<pre>photoresist )) and (((acid photoacid) near generat\$4) (photoactive near compound)) and</pre>	EPO; JPO; DERWENT	
		((basic adj compound) (nitrogen-containing	DERWENT	
		adj compound) ) and surfactant ) and	Ì	
		(dissolution adj inhibitor )) not (((thiol		
1		disulfide thiolsulfonate mercapto\$) and (ped		
		(post-exposure adj delay) (post adj exposure	1	
		adj delay) ) and (resist photoresist ) and		
		(((acid photoacid) near generat\$4)		
1		(photoactive near compound))) and		
		(surfactant (dissolution adj inhibitor)		!
		((basic adj compound) (nitrogen-containing		
		adj compound) ))) not ((thiol disulfide thiolsulfonate mercapto\$) same (ped		
		(post-exposure adj delay) (post adj exposure		
		adj delay) )))		
f -	2	(ped (post-exposure adj delay) (post adj	USPAT;	2003/09/03 11:28
		exposure adj delay)) near stabilizer	US-PGPUB;	
			EPO; JPO;	
			DERWENT	
-	0	(ped (post-exposure adj delay) (post adj	USPAT;	2003/09/03 11:24
		exposure adj delay)) near (additive)	US-PGPUB;	
			EPO; JPO;	
	2430	ned (negt-expenses add delaw) (nest add	DERWENT	2002/00/02 22 20
_	2430	ped (post-exposure adj delay) (post adj   exposure adj delay)	USPAT; US-PGPUB;	2003/09/03 11:19
		exposure adj deray)	EPO; JPO;	
			DERWENT	
_	2163	(thiol disulfide thiolsulfonate) near	USPAT;	2003/09/03 18:43
		derivative	US-PGPUB;	
			EPO; JPO;	
			DERWENT	
-	0	( F (F	USPAT;	2003/09/03 18:16
		exposure adj delay) ) same ((thiol	US-PGPUB;	
		disulfide thiolsulfonate) near derivative))	EPO; JPO;	
		not ((ped (post-exposure adj delay) (post adj exposure adj delay)) near stabilizer)	DERWENT	
_	١ ,	(ped (post-exposure adj delay) (post adj	USPAT;	2003/09/03 11:19
	*	exposure adj delay) ) same ((thiol	US-PGPUB;	2003/03/03 11:19
		disulfide thiolsulfonate) near derivative)	EPO; JPO;	
		,	DERWENT	
-	21	(ped (post-exposure adj delay) (post adj	USPAT;	2003/09/03 11:19
		exposure adj delay) ) and ((thiol disulfide	US-PGPUB;	
		thiolsulfonate) near derivative)	EPO; JPO;	
	1	2002202006 HDDN	DERWENT	2002/02/22 22 22
_	705		USPAT	2003/09/03 11:23 2003/09/03 11:24
_	/03	(chioi disuffide chioisuffonace) heaf agent	USPAT; US-PGPUB;	2003/09/03 11:24
	1	· V	EPO; JPO;	
			DERWENT	
-	10	(ped (post-exposure adj delay) (post adj	USPAT;	2003/09/03 11:24
		exposure adj delay)) near5 (agent)	US-PGPUB;	
		_	EPO; JPO;	•
			DERWENT	
-	236	(ped (post-exposure adj delay) (post adj	USPAT;	2003/09/03 11:29
		exposure adj delay)) near6 stabil\$6	US-PGPUB;	
			EPO; JPO;	.
_	1	((ped (post-exposure adj delay) (post adj	DERWENT USPAT;	2003/09/03 11:29
		exposure adj delay)) near6 stabil\$6) same	US-PGPUB;	2003/03/03 11:29
		((thiol disulfide thiolsulfonate) near	EPO; JPO;	
		derivative)	DERWENT	,
-	225	((ped (post-exposure adj delay) (post adj	USPAT;	2003/09/03 16:59
		exposure adj delay)) near6 stabil\$6) and	US-PGPUB;	
		(resist photoresist)	EPO; JPO;	
		Ano. 12. 2440 Ano. 21. 3513 Ano.	DERWENT	
-	126948	\$10thiol\$10 \$10disulfide\$10	USPAT;	2003/09/03 11:39
		\$10thiolsulfonate\$10	US-PGPUB;	
			EPO; JPO; DERWENT	
L	L		DEKMENI	1

-	11	'''E = 'E =   '	USPAT;	2003/09/03 11:52
		exposure adj delay)) near6 stabil\$6) and	US-PGPUB;	
		<pre>(resist photoresist)) and (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10 )</pre>	EPO; JPO; DERWENT	
_	2		USPAT;	2003/09/03 11:52
	-	( 0035000 7.211.	US-PGPUB;	2003/09/03 11:32
			EPO; JPO;	1
		·	DERWENT	
	0		USPAT	2003/09/03 12:07
j -	112931	THIOL DISULFIDE THIOLSULFONATE	USPAT;	2003/09/03 14:06
			US-PGPUB; EPO; JPO;	
			DERWENT	
_	7137	(THIOL DISULFIDE THIOLSULFONATE ) NEARS	USPAT;	2003/09/03 14:06
		DERIVATIVE	US-PGPUB;	
			EPO; JPO;	
	1564	//WYTOT DIGHT DIDD WYTOT GUT DOWN DO ) AND DE	DERWENT	
-	1564	((THIOL DISULFIDE THIOLSULFONATE ) NEAR5 DERIVATIVE) SAME STABIL\$6	USPAT;	2003/09/03 14:17
		DERIVATIVE) SAME STABILISO	US-PGPUB; EPO; JPO;	
			DERWENT	
-	121	(((THIOL DISULFIDE THIOLSULFONATE ) NEAR5	USPAT;	2003/09/03 14:17
	1	DERIVATIVE) SAME STABIL\$6) AND (RESIST	US-PGPUB;	
1.		PHOTORESIST)	EPO; JPO;	
·	1.5	(HC 6480080 & on HC 6305446 & on	DERWENT	0000/00/00 44 04
-	1 15	(US-6489080-\$ or US-6395446-\$ or US-6180316-\$ or US-6280897-\$ or US-6090518-\$	USPAT; US-PGPUB;	2003/09/03 14:26
		or US-6399272-\$).did. or (US-20020136981-\$	JPO	
		or US-20030148211-\$ or US-20030039916-\$ or	020	
		US-20020058206-\$ or US-20020015916-\$ or		
		US-20010044070-\$ or US-20030039918-\$ or		
		US-20020147259-\$).did. or		
_	120	((((THIOL DISULFIDE THIOLSULFONATE ) NEAR5	USPAT;	2002/00/02 14.26
	120	DERIVATIVE) SAME STABIL\$6) AND (RESIST	US-PGPUB;	2003/09/03 14:26
	ļ	PHOTORESIST)) NOT ((US-6489080-\$ or	EPO; JPO;	0
		US-6395446-\$ or US-6180316-\$ or US-6280897-\$	DERWENT	,
		or US-6090518-\$ or US-6399272-\$).did. or		
ļ	·	(US-20020136981-\$ or US-20030148211-\$ or		
		US-20030039916-\$ or US-20020058206-\$ or US-20020015916-\$ or US-20010044070-\$ or		
		US-20030039918-\$ or US-20020147259-\$).did.		
		or (JP-2002303986-\$).did.)		
-	120	(((((THIOL DISULFIDE THIOLSULFONATE ) NEAR5	USPAT;	2003/09/03 17:01
		DERIVATIVE) SAME STABIL\$6) AND (RESIST	US-PGPUB;	
		PHOTORESIST)) NOT ((US-6489080-\$ or US-6395446-\$ or US-6180316-\$ or US-6280897-\$	EPO; JPO; DERWENT	
		or US-6090518-\$ or US-6399272-\$).did. or	DEKMENI	
		(US-20020136981-\$ or US-20030148211-\$ or		
		US-20030039916-\$ or US-20020058206-\$ or		
		US-20020015916-\$ or US-20010044070-\$ or		
		US-20030039918-\$ or US-20020147259-\$).did.		
		or (JP-2002303986-\$).did.)) NOT (((ped (post-exposure adj delay) (post adj exposure		
		adj delay)) near stabilizer) ((ped		
		(post-exposure adj delay) (post adj exposure		
		adj delay) ) same ((thiol disulfide		
		thiolsulfonate) near derivative)) ((ped		
		(post-exposure adj delay) (post adj exposure		
	Į l	adj delay)) near5 (agent)) (((ped (post-exposure adj delay) (post adj exposure		
	[	adj delay)) near6 stabil\$6) same ((thiol		
		disulfide thiolsulfonate) near derivative))		
	]	((((ped (post-exposure adj delay) (post adj		
		exposure adj delay)) near6 stabil\$6) and		
		(resist photoresist)) and (\$10thiol\$10		
_	17642	\$10disulfide\$10 \$10thiolsulfonate\$10 )) ) ((acid photoacid) near generat\$4)	IICDAT.	2003/00/03 14 05
	1,642	(photoactive near compound)	USPAT; US-PGPUB;	2003/09/03 14:27
•			EPO; JPO;	
			DERWENT	

	266458	surfactant	USPAT;	2003/09/03 14:27
-	200436	Surractant	US-PGPUB;	2003/03/03 14.2/
<b>'</b>			EPO; JPO;	·
			DERWENT	
	0	((((((THIOL DISULFIDE THIOLSULFONATE ) NEARS	USPAT;	2003/09/03 14:27
_		DERIVATIVE) SAME STABIL\$6) AND (RESIST	US-PGPUB;	2003/03/03 14.2/
			EPO; JPO;	
	į	PHOTORESIST)) NOT ((US-6489080-\$ or US-6395446-\$ or US-6180316-\$ or US-6280897-\$	DERWENT	
ļ			DERWENT	
		or US-6090518-\$ or US-6399272-\$).did. or (US-20020136981-\$ or US-20030148211-\$ or		9
		US-20030039916-\$ or US-20020058206-\$ or		
:		US-20020015916-\$ or US-20010044070-\$ or		
		US-20030039918-\$ or US-20020147259-\$).did.		
		or (JP-2002303986-\$).did.)) NOT (((ped		
		(post-exposure adj delay) (post adj exposure		
		(post-exposure adj delay) (post adj exposure   adj delay)) near stabilizer) ((ped		
		(post-exposure adj delay) (post adj exposure		
		adj delay) ) same ((thiol disulfide		
		thiolsulfonate) near derivative)) ((ped		
		(post-exposure adj delay) (post adj exposure		
		adj delay)) near5 (agent)) (((ped		
		(post-exposure adj delay) (post adj exposure		
		adj delay)) near6 stabil\$6) same ((thiol		
		disulfide thiolsulfonate) near derivative))		
		((((ped (post-exposure adj delay) (post adj	•	
		exposure adj delay)) near6 stabil\$6) and	•	
		(resist photoresist)) and (\$10thiol\$10		
		\$10disulfide\$10 \$10thiolsulfonate\$10 ))))		
		AND (((acid photoacid) near generat\$4)		
		(photoactive near compound) ) AND surfactant		•
-	0	((((((THIOL DISULFIDE THIOLSULFONATE ) NEAR5	USPAT;	2003/09/03 14:28
		DERIVATIVE) SAME STABIL\$6) AND (RESIST	US-PGPUB;	
		PHOTORESIST)) NOT ((US-6489080-\$ or	EPO; JPO;	
		US-6395446-\$ or US-6180316-\$ or US-6280897-\$	DERWENT	•
	,	or US-6090518-\$ or US-6399272-\$).did. or		
		(US-20020136981-\$ or US-20030148211-\$ or		•
		US-20030039916-\$ or US-20020058206-\$ or		
		US-20020015916-\$ or US-20010044070-\$ or		
		US-20030039918-\$ or US-20020147259-\$).did.		
		or (JP-2002303986-\$).did.)) NOT (((ped	,	
		(post-exposure adj delay) (post adj exposure		
		adj delay)) near stabilizer) ((ped		
		(post-exposure adj delay) (post adj exposure		
		adj delay) ) same ((thiol disulfide		
		thiolsulfonate) near derivative)) ((ped		
		(post-exposure adj delay) (post adj exposure		
		adj delay)) near5 (agent)) (((ped		
		(post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) same ((thiol		
		disulfide thiolsulfonate) near derivative))		
		((((ped (post-exposure adj delay) (post adj		
		exposure adj delay)) near6 stabil\$6) and		
		(resist photoresist)) and (\$10thiol\$10		
1		\$10disulfide\$10 \$10thiolsulfonate\$10 )) ))		
		AND (((acid photoacid) near generat\$4)		•
1	1	(photoactive near compound) )	1	1

		<del></del>		
-	111	((((((THIOL DISULFIDE THIOLSULFONATE ) NEARS	USPAT;	2003/09/03 14:42
		DERIVATIVE) SAME STABIL\$6) AND (RESIST	US-PGPUB;	
		PHOTORESIST)) NOT ((US-6489080-\$ or	EPO; JPO;	-
		US-6395446-\$ or US-6180316-\$ or US-6280897-\$	DERWENT	1
1		or US-6090518-\$ or US-6399272-\$).did. or		1
		(US-20020136981-\$ or US-20030148211-\$ or		
		US-20030039916-\$ or US-20020058206-\$ or		!
		US-20020015916-\$ or US-20010044070-\$ or		
	1	US-20030039918-\$ or US-20020147259-\$).did.		
		or (JP-2002303986-\$).did.)) NOT (((ped		
		(post-exposure adj delay) (post adj exposure		
		adj delay)) near stabilizer) ((ped		
		(post-exposure adj delay) (post adj exposure	1	
		adj delay) ) same ((thiol disulfide		1
i				İ
	1	thiolsulfonate) near derivative)) ((ped		
	Ì	(post-exposure adj delay) (post adj exposure		
		adj delay)) near5 (agent)) (((ped		
		(post-exposure adj delay) (post adj exposure		
		adj delay)) near6 stabil\$6) same ((thiol		
		disulfide thiolsulfonate) near derivative))		
	1	((((ped (post-exposure adj delay) (post adj		
	1	exposure adj delay)) near6 stabil\$6) and		
		(resist photoresist)) and (\$10thiol\$10		
		\$10disulfide\$10 \$10thiolsulfonate\$10 ))))		· ·
		AND surfactant		
-	, 0	(((((((THIOL DISULFIDE THIOLSULFONATE)	USPAT;	2003/09/03 15:04
		NEAR5 DERIVATIVE) SAME STABIL\$6) AND (RESIST	US-PGPUB;	
		PHOTORESIST)) NOT ((US-6489080-\$ or	EPO; JPO;	
		US-6395446-\$ or US-6180316-\$ or US-6280897-\$	DERWENT	
		or US-6090518-\$ or US-6399272-\$).did. or		
	·	(US-20020136981-\$ or US-20030148211-\$ or		
		US-20030039916-\$ or US-20020058206-\$ or		
	1	US-20020015916-\$ or US-20010044070-\$ or		
		US-20030039918-\$ or US-20020147259-\$).did.		1
		or (JP-2002303986-\$).did.)) NOT (((ped		
		(post-exposure adj delay) (post adj exposure		
		adj delay)) near stabilizer) ((ped		
		(post-exposure adj delay) (post adj exposure		
		adj delay) ) same ((thiol disulfide		
		thiolsulfonate) near derivative)) ((ped		
		(post-exposure adj delay) (post adj exposure		
		adj delay)) near5 (agent)) (((ped		
	1	(post-exposure adj delay) (post adj exposure		
		adj delay)) near6 stabil\$6) same ((thiol		
		disulfide thiolsulfonate) near derivative))		
1 .		((((ped (post-exposure adj delay) (post adj		
		exposure adj delay)) near6 stabil\$6) and		
		(resist photoresist)) and (\$10thiol\$10		
		(resist photoresist) and (\$10th101\$10   \$10disulfide\$10 \$10th101sulfonate\$10 )) ))		
}				
_	5	AND surfactant ) AND (430/\$.CCLS.) (("5589312") or ("5344694")).PN.	HCDATT.	2003/09/03 15:05
-	)	(	USPAT;	2003/09/03 .15:05
	1		US-PGPUB;	
			EPO; JPO;	
		020CF00 A 444	DERWENT	
-	2	wo-9306529-\$.did.	USPAT;	2003/09/03 15:06
			US-PGPUB;	
			EPO; JPO;	
1			DERWENT	
-	7	((("5589312") or ("5344694")).PN.) or	USPAT;	2003/09/03 15:06
1		wo-9306529-\$.did.	US-PGPUB;	
1 .			EPO; JPO;	
1	1		DERWENT	
-	8055	(430/270.1 430/296 430/326 430/330 430/327	USPAT;	2003/09/03 18:43
1		430/913 430/917 430/921 430/942).ccls.	US-PGPUB;	
			EPO; JPO;	
			DERWENT	•
-	31	((430/270.1 430/296 430/326 430/330 430/327	USPAT;	2003/09/03 15:22
1	T	430/913 430/917 430/921 430/942).ccls.) and	US-PGPUB;	· · · · · · · · · · · · · · · · · · ·
	]	((thiol disulfide thiolsulfonate) near	EPO; JPO;	
		derivative)	DERWENT	
		· · · · · · · · · · · · · · · · · · ·		

r				
-	31	(((430/270.1 430/296 430/326 430/330 430/327	USPAT;	2003/09/03 15:22
		430/913 430/917 430/921 430/942).ccls.) and	US-PGPUB;	
		((thiol disulfide thiolsulfonate) near	EPO; JPO;	
•		derivative)) not (((("5589312") or	DERWENT	
		("5344694")).PN.) or wo-9306529-\$.did. )		
-	31	((((430/270.1 430/296 430/326 430/330	USPAT;	2003/09/03 15:22
		430/327 430/913 430/917 430/921	US-PGPUB;	
		430/942).ccls.) and ((thiol disulfide	EPO; JPO;	-
		thiolsulfonate) near derivative)) not	DERWENT	
		(((("5589312") or ("5344694")).PN.) or	1	
•		wo-9306529-\$.did. )) not (((((THIOL		1
		DISULFIDE THIOLSULFONATE ) NEAR5 DERIVATIVE)		İ
		SAME STABIL\$6) AND (RESIST PHOTORESIST)) NOT		
		((US-6489080-\$ or US-6395446-\$ or		
		US-6180316-\$ or US-6280897-\$ or US-6090518-\$		
		or US-6399272-\$).did. or (US-20020136981-\$		
		or US-20030148211-\$ or US-20030039916-\$ or		
		US-20020058206-\$ or US-20020015916-\$ or		
		US-20010044070-\$ or US-20030039918-\$ or		
i		US-20020147259-\$).did. or		
:		(JP-2002303986-\$).did.)) NOT (((ped		
		(post-exposure adj delay) (post adj exposure		
,		adj delay)) near stabilizer) ((ped		
, 1		(post-exposure adj delay) (post adj exposure		
		adj delay) ) same ((thiol disulfide		
		thiolsulfonate) near derivative)) ((ped		
		(post-exposure adj delay) (post adj exposure		
		adj delay)) near5 (agent)) (((ped		
,		(post-exposure adj delay) (post adj exposure		
		adj delay)) near6 stabil\$6) same ((thiol		
		disulfide thiolsulfonate) near derivative))		
		((((ped (post-exposure adj delay) (post adj		
		exposure adj delay)) near6 stabil\$6) and		
. 1		(resist photoresist)) and (\$10thiol\$10		
		\$10disulfide\$10 \$10thiolsulfonate\$10 ))))		

	·			
-	30	(((((430/270.1 430/296 430/326 430/330	USPAT;	2003/09/03 16:59
		430/327 430/913 430/917 430/921   430/942).ccls.) and ((thiol disulfide	US-PGPUB; EPO; JPO;	
		thiolsulfonate) near derivative)) not	DERWENT	
		(((("5589312") or ("5344694")).PN.) or		
		wo-9306529-\$.did. )) not (((((THIOL		
		DISULFIDE THIOLSULFONATE ) NEARS DERIVATIVE)	}	
		SAME STABIL\$6) AND (RESIST PHOTORESIST)) NOT		
		((US-6489080-\$ or US-6395446-\$ or		
		US-6180316-\$ or US-6280897-\$ or US-6090518-\$		
		or US-6399272-\$).did. or (US-20020136981-\$		
		or US-20030148211-\$ or US-20030039916-\$ or		
		US-20020058206-\$ or US-20020015916-\$ or		
		US-20010044070-\$ or US-20030039918-\$ or		•
		US-20020147259-\$).did. or   (JP-2002303986-\$).did.)) NOT (((ped		
		(post-exposure adj delay) (post adj exposure		
		adj delay)) near stabilizer) ((ped		
		(post-exposure adj delay) (post adj exposure		
		adj delay) ) same ((thiol disulfide		
		thiolsulfonate) near derivative)) ((ped		
l .		(post-exposure adj delay) (post adj exposure		
		adj delay)) near5 (agent)) (((ped		
		(post-exposure adj delay) (post adj exposure		
		adj delay)) near6 stabil\$6) same ((thiol		
		disulfide thiolsulfonate) near derivative))		
		((((ped (post-exposure adj delay) (post adj exposure adj delay)) near6 stabil\$6) and		
		(resist photoresist)) and (\$10thiol\$10		
		\$10disulfide\$10 \$10thiolsulfonate\$10 )))))		
		NOT (((ped (post-exposure adj delay) (post		
'	1	adj exposure adj delay)) near stabilizer)		
İ	İ	((ped (post-exposure adj delay) (post adj		
		exposure adj delay) ) same ((thiol		
		disulfide thiolsulfonate) near derivative))		
		((ped (post-exposure adj delay) (post adj exposure adj delay)) near5 (agent)) (((ped		
		(post-exposure adj delay) (post adj exposure		
		adj delay)) near6 stabil\$6) same ((thiol		
		disulfide thiolsulfonate) near derivative))		
		((((ped (post-exposure adj delay) (post adj		
		exposure adj delay)) near6 stabil\$6) and		
		(resist photoresist)) and (\$10thiol\$10		-
		\$10disulfide\$10 \$10thiolsulfonate\$10 )))		
<b>-</b> ·	246076	stabilizer	USPAT;	2003/09/03 17:51
		·	US-PGPUB;	
			EPO; JPO; DERWENT	
_	12420	stabilizer and (resist photoresist)	USPAT;	2003/09/03 16:59
	12320	Translation with the translation business business the translation of	US-PGPUB;	2003/03/03 10:39
			EPO; JPO;	
			DERWENT	
<b>-</b>	1.7642	((acid photoacid) near generat\$4)	USPAT;	2003/09/03 16:59
		(photoactive near compound)	US-PGPUB;	, i
			EPO; JPO;	
ı	00101		DERWENT	
_	22496	(basic adj compound) (nitrogen-containing	USPAT;	2003/09/03 16:59
		adj compound)	US-PGPUB;	`
			EPO; JPO; DERWENT	
	266458	surfactant	USPAT;	2003/09/03 16:59
,			US-PGPUB;	
			EPO; JPO;	
, I			DERWENT	
-	1096	dissolution adj inhibitor	USPAT;	2003/09/03 17:00
,			US-PGPUB;	
, .	_		EPO; JPO;	
			DERWENT	

-	42	(stabilizer and (resist photoresist)) and	USPAT;	2003/09/03 17:00
1		(((acid photoacid) near generat\$4)	US-PGPUB;	
		(photoactive near compound) ) and ((basic	EPO; JPO;	
		adj compound) (nitrogen-containing adj	DERWENT	
		compound) ) and surfactant and	1	
		(dissolution adj inhibitor )		,
-	41	((stabilizer and (resist photoresist)) and	USPAT;	2003/09/03 17:01
		(((acid photoacid) near generat\$4)	US-PGPUB;	
		(photoactive near compound) ) and ((basic	EPO; JPO;	
		adj compound) (nitrogen-containing adj	DERWENT	
		compound) ) and surfactant and		
		(dissolution adj inhibitor )) NOT (((ped		
1		(post-exposure adj delay) (post adj exposure		
		adj delay)) near stabilizer) ((ped		
		(post-exposure adj delay) (post adj exposure		
		adj delay) ) same ((thiol disulfide		
		thiolsulfonate) near derivative)) ((ped		
		(post-exposure adj delay) (post adj exposure		
		adj delay)) near5 (agent)) (((ped		
		(post-exposure adj delay) (post adj exposure		
		adj delay)) near6 stabil\$6) same ((thiol		
		disulfide thiolsulfonate) near derivative))		•
		((((ped (post-exposure adj delay) (post adj		
		exposure adj delay)) near6 stabil\$6) and	ĺ	
		(resist photoresist)) and (\$10thiol\$10		
		<pre>\$10disulfide\$10 \$10thiolsulfonate\$10 )) )</pre>		

	1 41	///shahili and /wasish photograph) and	HODAM	1 2002 /00 /02 12 00
-	41	(((stabilizer and (resist photoresist)) and	USPAT;	2003/09/03 17:02
Ì		(((acid photoacid) near generat\$4)	US-PGPUB;	
		(photoactive near compound) ) and ((basic	EPO; JPO;	
		adj compound) (nitrogen-containing adj	DERWENT	
		compound) ) and surfactant and		
		(dissolution adj inhibitor )) NOT (((ped		
	0	(post-exposure adj delay) (post adj exposure		i l
		adj delay)) near stabilizer) ((ped		İ
		(post-exposure adj delay) (post adj exposure		į į
		adj delay) ) same ((thiol disulfide		
		thiolsulfonate) near derivative)) ((ped		
1		(post-exposure adj delay) (post adj exposure		
		adj delay)) near5 (agent)) (((ped		
		(post-exposure adj delay) (post adj exposure		
		adj delay)) near6 stabil\$6) same ((thiol		
	1	disulfide thiolsulfonate) near derivative))		
		((((ped (post-exposure adj delay) (post adj		
	1	exposure adj delay)) near6 stabil\$6) and		
		(resist photoresist)) and (\$10thiol\$10		
		\$10disulfide\$10 \$10thiolsulfonate\$10 )) ))	1	
		not ((((((430/270.1 430/296 430/326 430/330		
		430/327 430/913 430/917 430/921		
		l · ·		
		430/942).ccls.) and ((thiol disulfide		
	Ī	thiolsulfonate) near derivative)) not		
		(((("5589312") or ("5344694")).PN.) or		
		wo-9306529-\$.did. )) not (((((THIOL	ļ	
		DISULFIDE THIOLSULFONATE ) NEARS DERIVATIVE)		
		SAME STABILS6) AND (RESIST PHOTORESIST)) NOT		
		((US-6489080-\$ or US-6395446-\$ or		
		US-6180316-\$ or US-6280897-\$ or US-6090518-\$		
		or US-6399272-\$).did. or (US-20020136981-\$		
ĺ	•	or US-20030148211-\$ or US-20030039916-\$ or		
		US-20020058206-\$ or US-20020015916-\$ or		ļ
		US-20010044070-\$ or US-20030039918-\$ or		
		US-20020147259-\$).did. or		
-	İ	(JP-2002303986-\$).did.)) NOT (((ped		
1		(post-exposure adj delay) (post adj exposure		
}	1	adj delay)) near stabilizer) ((ped		
		(post-exposure adj delay) (post adj exposure		
		adj delay) ) same ((thiol disulfide		·
		thiolsulfonate) near derivative)) ((ped		
		(post-exposure adj delay) (post adj exposure		1
		adj delay)) near5 (agent)) (((ped		
		(post-exposure adj delay) (post adj exposure		]
		adj delay)) near6 stabil\$6) same ((thiol		1
		disulfide thiolsulfonate) near derivative))		
		((((ped (post-exposure adj delay) (post adj		0.00
	<u> </u>	exposure adj delay)) near6 stabil\$6) and		
	1	(resist photoresist)) and (\$10thiol\$10		·
		\$10disulfide\$10 \$10thiolsulfonate\$10 )) )))		
		NOT (((ped (post-exposure adj delay) (post		
		adj exposure adj delay)) near stabilizer)		
		((ped (post-exposure adj delay) (post adj		
		exposure adj delay) ) same ((thiol		
		disulfide thiolsulfonate) near derivative))		
		((ped (post-exposure adj delay) (post adj		
1 .		exposure adj delay)) near5 (agent)) (((ped		
1		(post-exposure adj delay) (post adj exposure		*
		adj delay)) near6 stabil\$6) same ((thiol		
		disulfide thiolsulfonate) near derivative))		
		((((ped (post-exposure adj delay) (post adj		
				.
		exposure adj delay)) near6 stabil\$6) and		
		(resist photoresist)) and (\$10thiol\$10		
ļ	055	\$10disulfide\$10 \$10thiolsulfonate\$10 )) ))	LICDATE	2002/00/02 10/01
1 -	855	stabilizer and ((430/270.1 430/296 430/326	USPAT;	2003/09/03 18:01
		430/330 430/327 430/913 430/917 430/921	US-PGPUB;	
		430/942).ccls.)	EPO; JPO;	- [
		(ababilinam came (/bbis] di-arsia-	DERWENT	2002/02/22 27 75
-	1	(stabilizer same ((thiol disulfide	USPAT;	2003/09/03 17:53
		thiolsulfonate) near derivative)) and	US-PGPUB;	
		((430/270.1 430/296 430/326 430/330 430/327	EPO; JPO;	·
L	L	430/913 430/917 430/921 430/942).ccls.)	DERWENT	

-	53	stabilizer same ((thiol disulfide	USPAT;	2003/09/03 17:54
	1	thiolsulfonate) near derivative)	US-PGPUB;	
			EPO; JPO;	
			DERWENT	
-	854	(stabilizer and ((430/270.1 430/296 430/326	USPAT;	2003/09/03 18:02
		430/330 430/327 430/913 430/917 430/921	US-PGPUB;	
•	'	430/942).ccls.)) not (stabilizer same	EPO; JPO;	
		((thiol disulfide thiolsulfonate) near	DERWENT	
		derivative))		
-	706	(stabilizer and ((430/270.1 430/296 430/326	USPAT	2003/09/03 18:02
		430/330 430/327 430/913 430/917 430/921		
	1	430/942).ccls.)) not (stabilizer same		
	İ	((thiol disulfide thiolsulfonate) near		
	116	derivative))	HODAM	2002/00/02 10 50
_	110	stabil\$6 same ((thiol disulfide   thiolsulfonate) near derivative)	USPAT;	2003/09/03 18:50
		thioisulfonate, hear derivative,	US-PGPUB; EPO; JPO;	
			DERWENT	
_	1	(stabil\$6 same ((thiol disulfide	USPAT;	2003/09/03 18:51
_	1	thiolsulfonate) near derivative) ) and	US-PGPUB;	2003/09/03 18:51
	İ	(resist photoresist)	EPO; JPO;	
	İ	(100100 photorebise)	DERWENT	
_	8055	(430/270.1 430/296 430/326 430/330 430/327	USPAT;	2003/09/03 18:43
		430/913 430/917 430/921 430/942).ccls.	US-PGPUB;	2003, 03, 03
			EPO; JPO;	
		·	DERWENT	
_	2163	(thiol disulfide thiolsulfonate) near	USPAT;	2003/09/03 18:50
	ļ	derivative	US-PGPUB;	
			EPO; JPO;	
			DERWENT	
-	126948	\$10thiol\$10 \$10disulfide\$10	USPAT;	2003/09/03 18:44
		\$10thiolsulfonate\$10	US-PGPUB;	
			EPO; JPO;	[
			DERWENT	
<b>-</b> ·	127073	((thiol disulfide thiolsulfonate) near	USPAT;	2003/09/03 18:50
		derivative ) (\$10thiol\$10 \$10disulfide\$10	US-PGPUB;	
		\$10thiolsulfonate\$10 )	EPO; JPO;	
_	10164	   stabil\$6 same (((thiol disulfide	DERWENT USPAT;	2003/09/03 18:50
	10104	thiolsulfonate) near derivative )	US-PGPUB;	2003/09/03 18:50
		(\$10thiol\$10 \$10disulfide\$10	EPO; JPO;	
		\$10thiolsulfonate\$10 ))	DERWENT	
_	701	(stabil\$6 same (((thiol disulfide	USPAT;	2003/09/03 19:55
		thiolsulfonate) near derivative )	US-PGPUB;	
		(\$10thiol\$10 \$10disulfide\$10	EPO; JPO;	
		\$10thiolsulfonate\$10 ) )) and (resist	DERWENT	
		photoresist)		,
-	34	((stabil\$6 same (((thiol disulfide	USPAT;	2003/09/03 19:55
		thiolsulfonate) near derivative )	US-PGPUB;	
		(\$10thiol\$10 \$10disulfide\$10	EPO; JPO;	
		\$10thiolsulfonate\$10 ) )) and (resist	DERWENT	
		photoresist)) and ((430/270.1 430/296		
		430/326 430/330 430/327 430/913 430/917		
		430/921 430/942).ccls.)		0000/00/00
-	6896	(((thiol disulfide thiolsulfonate) near	USPAT;	2003/09/03 19:55
		derivative ) (\$10thiol\$10 \$10disulfide\$10	US-PGPUB;	
	1 .	\$10thiolsulfonate\$10 ) ) and (resist   photoresist)	EPO; JPO; DERWENT	
_	E27	pnotoresist)   ((((thiol_disulfide thiolsulfonate) near		2002/00/02 10 55
_	34/	derivative ) (\$10thiol\$10 \$10disulfide\$10	USPAT; US-PGPUB;	2003/09/03 19:55
		\$10thiolsulfonate\$10 ) ) and (resist	EPO; JPO;	
		photoresist)) and ((430/270.1 430/296	DERWENT	
	,	430/326 430/330 430/327 430/913 430/917	DERMENT.	
		430/921 430/942).ccls.)		
				L

-	493	((((thiol disulfide thiolsulfonate) near	USPAT;	2003/09/03 19:55
		derivative ) (\$10thiol\$10 \$10disulfide\$10	US-PGPUB;	
		\$10thiolsulfonate\$10 ) ) and (resist	EPO; JPO;	
Ī		photoresist)) and ((430/270.1 430/296	DERWENT	
		430/326 430/330 430/327 430/913 430/917		
		430/921 430/942).ccls. )) not (((stabil\$6		
		same (((thiol disulfide thiolsulfonate) near		
		derivative ) (\$10thiol\$10 \$10disulfide\$10		]
		\$10thiolsulfonate\$10 ))) and (resist	İ	
		photoresist)) and ((430/270.1 430/296		
		430/326 430/330 430/327 430/913 430/917		
1	222	430/921 430/942).ccls.))		0000/00/00 00 00
- '	233	((((((thiol disulfide thiolsulfonate) near	USPAT;	2003/09/03 19:59
		derivative ) (\$10thiol\$10 \$10disulfide\$10 \$10thiolsulfonate\$10 ) ) and (resist	US-PGPUB;	
		photoresist)) and ((430/270.1 430/296	EPO; JPO; DERWENT	
		430/326 430/330 430/327 430/913 430/917	DERWENT	
,		430/921 430/942).ccls. )) not (((stabil\$6	i	
		same (((thiol disulfide thiolsulfonate) near		l i
		derivative ) (\$10thiol\$10 \$10disulfide\$10		
		\$10thiolsulfonate\$10 ) )) and (resist		
		photoresist)) and ((430/270.1 430/296		
		430/326 430/330 430/327 430/913 430/917		
		430/921 430/942).ccls. ))) and (\$5acid near		
		generat\$3)		
-	233	((((((thiol disulfide thiolsulfonate) near	USPAT;	2003/09/03 19:59
	_	derivative ) (\$10thiol\$10 \$10disulfide\$10	US-PGPUB;	
		\$10thiolsulfonate\$10 ) ) and (resist	EPO; JPO;	
		photoresist)) and ((430/270.1 430/296	DERWENT	
		430/326 430/330 430/327 430/913 430/917		
		430/921 430/942).ccls. )) not (((stabil\$6		
		same (((thiol disulfide thiolsulfonate) near		
		derivative ) (\$10thiol\$10 \$10disulfide\$10		
		\$10thiolsulfonate\$10 ) )) and (resist		
		photoresist)) and ((430/270.1 430/296		
		430/326 430/330 430/327 430/913 430/917		
		430/921 430/942).ccls. ))) and (\$5acid near		ĺ
•		<pre>generat\$3) ) not (((stabil\$6 same (((thiol</pre>		
		disulfide thiolsulfonate) near derivative )		
		(\$10thiol\$10 \$10disulfide\$10		
		\$10thiolsulfonate\$10 ) )) and (resist		
		photoresist)) and ((430/270.1 430/296 430/326 430/330 430/327 430/913 430/917		
		430/326 430/330 430/32/ 430/913 430/91/   430/921 430/942).ccls. ))		
_	233	(((((((thiol disulfide thiolsulfonate) near	USPAT;	2003/09/03 19:59
	2,5	derivative ) (\$10thiol\$10 \$10disulfide\$10	US-PGPUB;	2003/03/03 13:53
		\$10thiolsulfonate\$10 ) ) and (resist	EPO; JPO;	
		photoresist)) and ((430/270.1 430/296	DERWENT	
		430/326 430/330 430/327 430/913 430/917		
		430/921 430/942).ccls. )) not (((stabil\$6		
		same (((thiol disulfide thiolsulfonate) near		
		derivative ) (\$10thiol\$10 \$10disulfide\$10		
		\$10thiolsulfonate\$10 ) )) and (resist		
		photoresist)) and ((430/270.1 430/296		
		430/326 430/330 430/327 430/913 430/917		
		430/921 430/942).ccls. ))) and (\$5acid near		
		<pre>generat\$3) ) not (((stabil\$6 same (((thiol</pre>		
]		disulfide thiolsulfonate) near derivative)		
		(\$10thiol\$10 \$10disulfide\$10		
		\$10thiolsulfonate\$10 ))) and (resist		
		photoresist)) and ((430/270.1 430/296		
		430/326 430/330 430/327 430/913 430/917		
		430/921 430/942).ccls. ))) and ((430/270.1 430/296 430/326 430/330 430/327 430/913		
		430/296 430/326 430/330 430/32/ 430/913 430/917 430/921 430/942).ccls.)		•
		430/311 430/321 430/342).CC18. )		